



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Continuation-in-part application of

David Y. Kao, et al.

Serial No.: 08/720,693

Filed: October 2, 1996

For: OXIDATION OF ION IMPLANTED
SEMICONDUCTORS

Examiner: George Fourson

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REQUEST FOR RESPONSE PERIOD TO BE RESET UNDER MPEP 710.06

Honorable Commissioner of Patents
and Trademarks
Washington, D.C. 20231

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In response to the Office Action mailed February 13, 1998 ("the Office Action"),

Applicants submit the following remarks:

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1. Remarks

Applicants wish to thank the Examiner for his response for a request to transmit by facsimile a copy of the Office Action on March 10, 1998 due to the absence of Page 5 from Applicants' copy of the Office Action. Applicants are now in receipt of the facsimile transmission of the Office Action, including Page 5 therewith.

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